

**Realization of vertical metal/semiconductor heterostructures via
solution-phase epitaxy**

Wang *et al.*

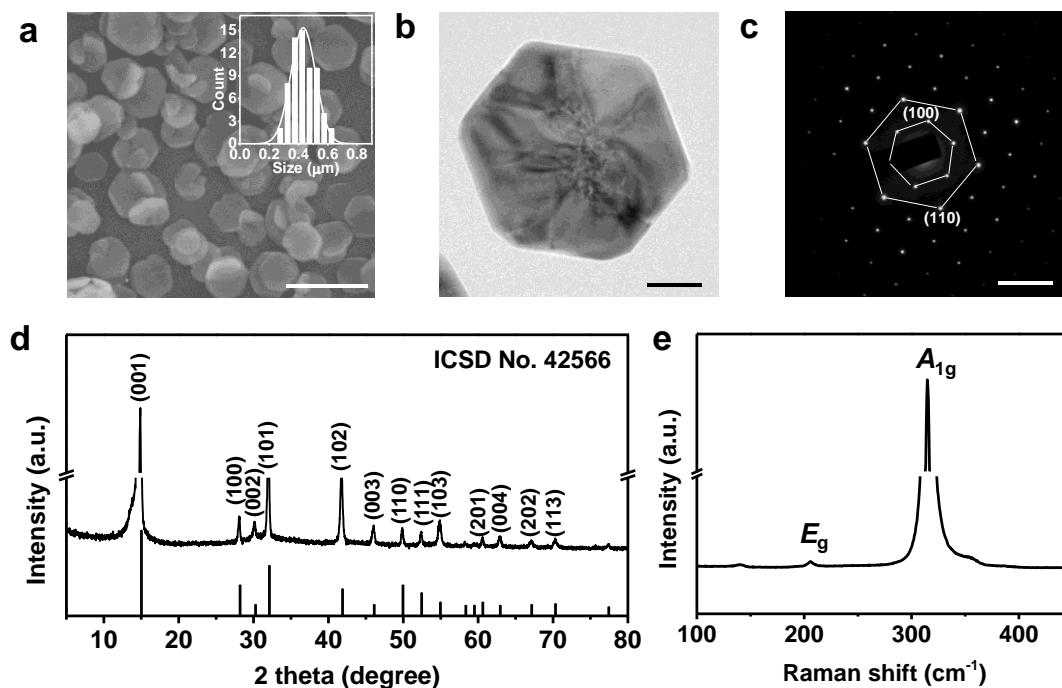
Supplementary Information

Realization of vertical metal/semiconductor heterostructures via solution-phase epitaxy

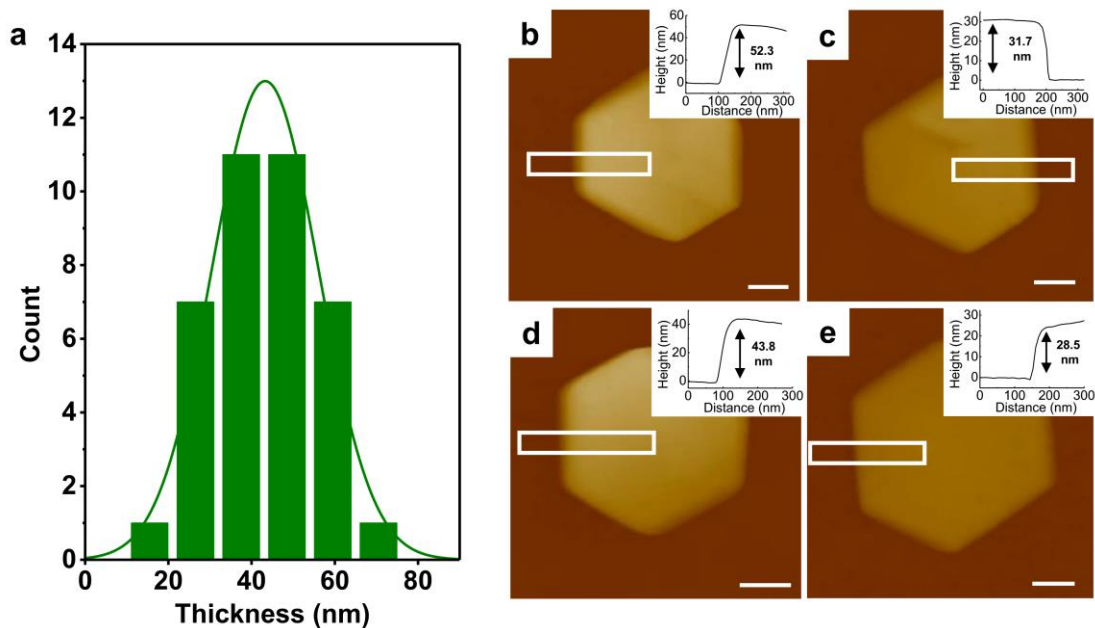
Xiaoshan Wang^{‡1}, Zhiwei Wang^{‡1}, Jindong Zhang¹, Xiang Wang¹, Zhipeng Zhang¹, Jialiang Wang¹, Zhaohua Zhu¹, Zhuoyao Li¹, Yao Liu¹, Xuefeng Hu², Junwen Qiu², Guohua Hu³, Bo Chen⁴, Ning Wang^{1,4}, Qiyuan He⁴, Junze Chen⁴, Jiaxu Yan¹, Wei Zhang², Tawfique Hasan³, Shaozhou Li⁵, Hai Li¹, Hua Zhang⁴, Qiang Wang^{6*}, Xiao Huang^{1*}, Wei Huang^{1,5,7*}

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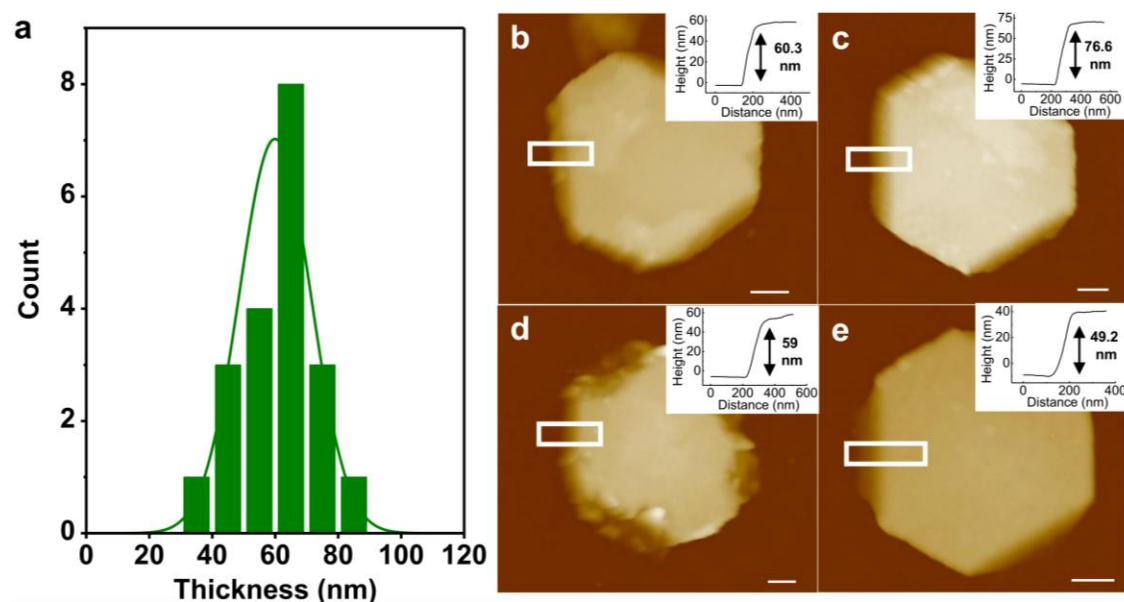
Supplementary Figures



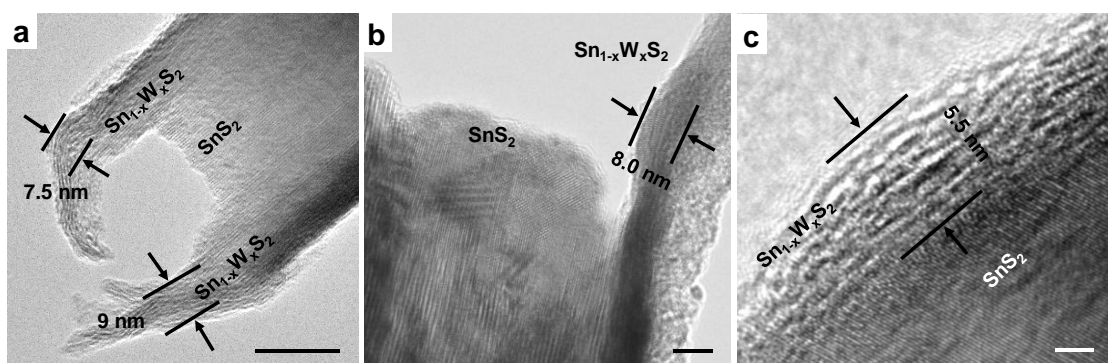
Supplementary Figure 1. (a) SEM image (scale bar, 500 nm), (b) TEM image (scale bar, 100 nm), (c) SAED pattern (scale bar, 5 nm⁻¹), (d) XRD pattern and (e) Raman spectrum of SnS₂ nanoplates. Inset of (a): lateral size distribution of the nanoplates. Raman spectrum in (e) shows two dominant peaks at 205 and 314 cm⁻¹ corresponding to the E_g and A_{1g} vibrational modes of SnS₂, respectively¹.



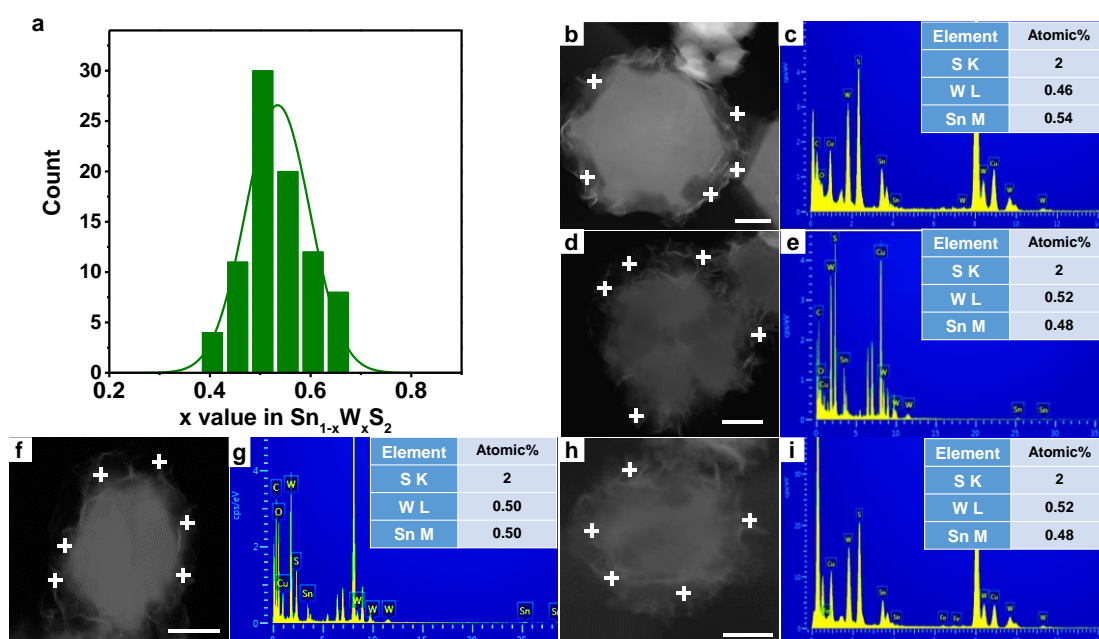
Supplementary Figure 2. (a) Thickness distribution of SnS₂ nanoplates showing a mean thickness of ~43 nm. (b-e) Examples of AFM images and height analyses of individual SnS₂ nanoplates (scale bars, 100 nm). Insets: height analysis of the region highlighted in the corresponding white rectangle.



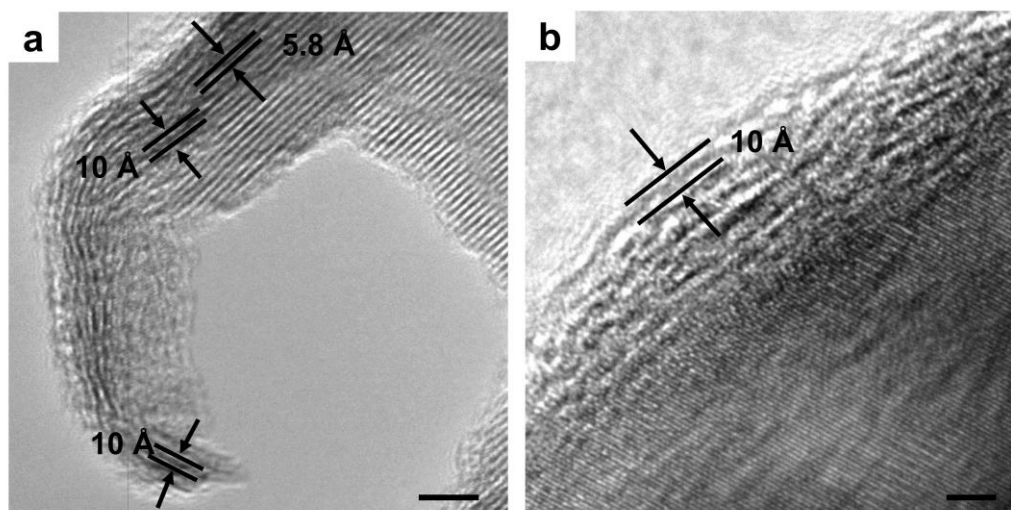
Supplementary Figure 3. (a) Thickness distribution of Sn_{1-x}W_xS₂/SnS₂ heterstructures, showing a mean thickness of ~60 nm. (b-e) Examples of AFM images and height analyses of individual Sn_{1-x}W_xS₂/SnS₂ heterstructures (scale bars, 100 nm). Insets: height analysis of the region highlighted in the corresponding white rectangle.



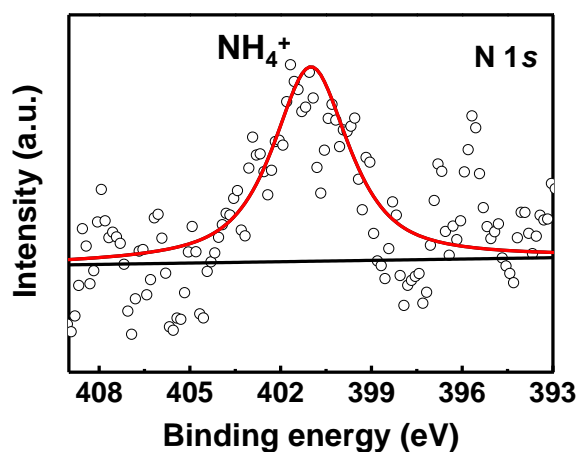
Supplementary Figure 4. (a-c) Side-view TEM images of typical $\text{Sn}_{1-x}\text{W}_x\text{S}_2/\text{SnS}_2$ heterostructures, revealing that the thickness of $\text{Sn}_{1-x}\text{W}_x\text{S}_2$ nanosheets grown on SnS_2 nanoplates is 6-9 nm. The scale bars in (a), (b) and (c) are 20 nm, 5 nm and 2 nm, respectively.



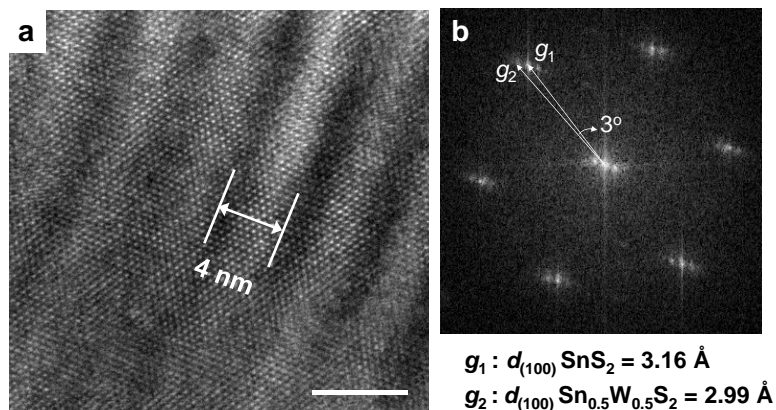
Supplementary Figure 5. (a) Distribution of x values in $\text{Sn}_{1-x}\text{W}_x\text{S}_2$ based on EDX spot analyses on the edges of several $\text{Sn}_{1-x}\text{W}_x\text{S}_2$. (b-i) Four examples of STEM images and EDX spot analyses on the edges of $\text{Sn}_{1-x}\text{W}_x\text{S}_2$ nanosheets, where the positions of the analyzed spots are highlighted in white crosses (scale bars, 200 nm). A mean value of ~ 0.5 was determined for x .



Supplementary Figure 6. (a,b) Side-view HRTEM images of typical $\text{Sn}_{0.5}\text{W}_{0.5}\text{S}_2/\text{SnS}_2$ heterostructures, revealing surface deposited $\text{Sn}_{0.5}\text{W}_{0.5}\text{S}_2$ nanosheets with varied interlayer spacings. The scale bars in (a) and (b) are 5 nm and 2 nm, respectively.

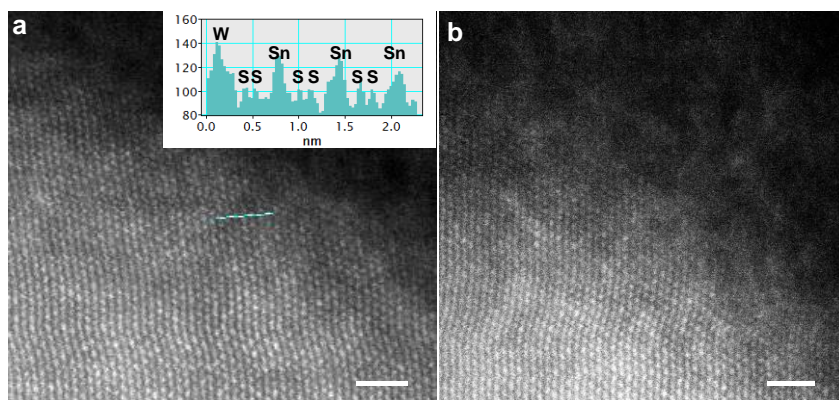


Supplementary Figure 7. XPS N 1s spectrum of as-prepared $\text{Sn}_{0.5}\text{W}_{0.5}\text{S}_2/\text{SnS}_2$ heterostructures, showing a peak at 401.1 eV, which can be assigned to NH_4^+ (ref. 2).

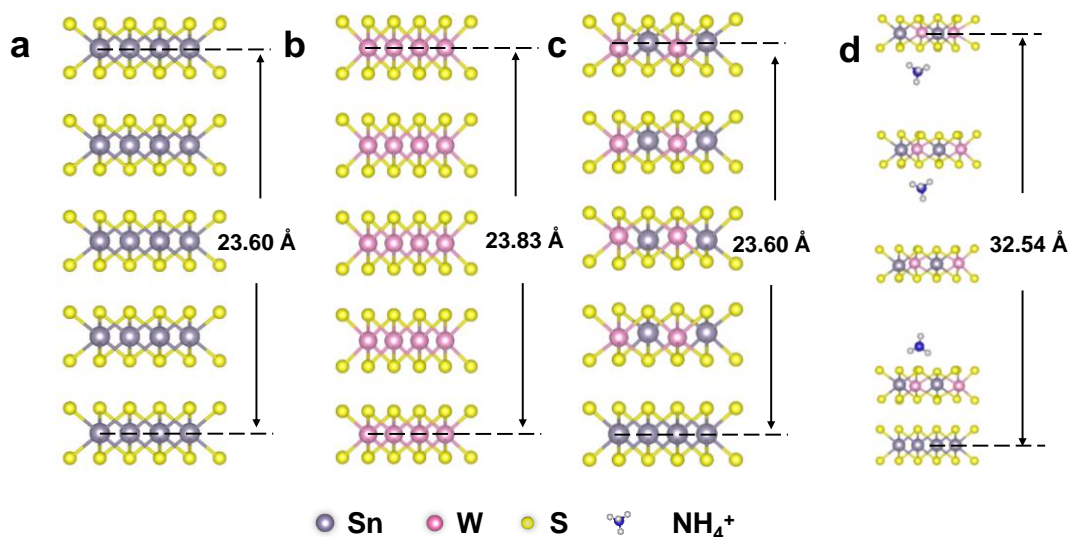


Supplementary Figure 8. (a) HRTEM image of a typical $\text{Sn}_{0.5}\text{W}_{0.5}\text{S}_2/\text{SnS}_2$ heterostructure lying flatly on a copper grid, showing a Moiré pattern with a periodicity of ~ 4.0 nm (scale bar, 5 nm). (b) Fast Fourier transform (FFT) diffraction pattern of (a), showing reciprocal vectors of g_1 and g_2 corresponding to the (100) planes of SnS_2 and $\text{Sn}_{0.5}\text{W}_{0.5}\text{S}_2$, with real space spacing d_1 and d_2 equaling to 3.16 and 2.99 Å, respectively.

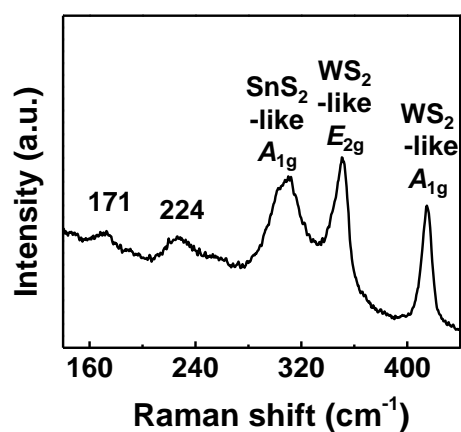
The Moiré pattern based on equation $d = \frac{d_1 d_2}{\sqrt{d_1^2 + d_2^2 - 2d_1 d_2 \cos \theta}}$ has a calculated pattern periodicity of ~ 4.0 nm, consistent with the measurement in (a).



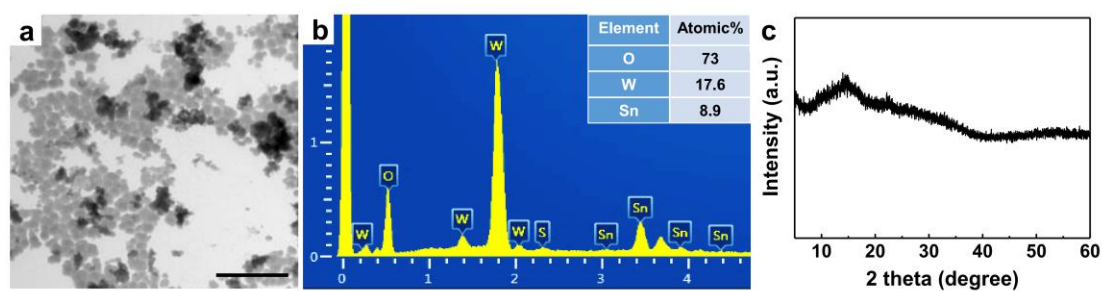
Supplementary Figure 9. (a,b) STEM images of the edge area of a typical $\text{Sn}_{0.5}\text{W}_{0.5}\text{S}_2/\text{SnS}_2$ heterostructure lying flatly on a copper grid (scale bars, 2 nm). The inset of (a) shows the contrast profile of the line marked in the image, indicating a typical metal-sulfur-sulfur-metal atomic pattern for 1T-phase-like structure³. From the thin area near the edge, contrast difference due to the presence of Sn and W elements can be observed.



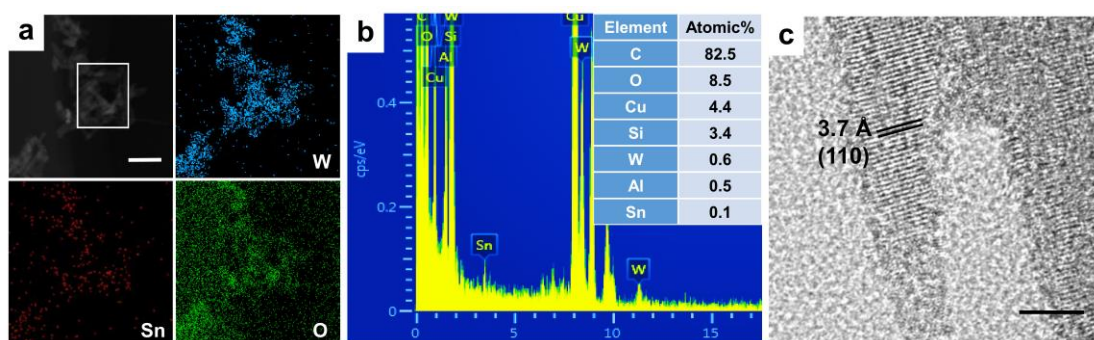
Supplementary Figure 10. Calculated structural models of (a) SnS_2 , (b) 1T-WS_2 , (c) a four-layer distorted $1\text{T-Sn}_{0.5}\text{W}_{0.5}\text{S}_2$ on a monolayer 1T-SnS_2 and (d) a four-layer distorted $1\text{T-Sn}_{0.5}\text{W}_{0.5}\text{S}_2$ on a monolayer 1T-SnS_2 with intercalated NH_4^+ ions. The optimized crystal structures of a five-layer SnS_2 , a five-layer 1T-WS_2 and a four-layer distorted $1\text{T-Sn}_{0.5}\text{W}_{0.5}\text{S}_2$ on a monolayer 1T-SnS_2 with and without NH_4^+ intercalated ions are shown in Fig. 10 and Table 1. In a 5-layer SnS_2 , the Sn-S bond length is about 2.58 Å, while the W-S bond length in a 5-layer WS_2 is about 2.42 Å. The interlayer distance along the c-axis of SnS_2 is 5.90 ± 0.03 Å, shorter than that of WS_2 by ~ 0.10 Å. For $\text{Sn}_{0.5}\text{W}_{0.5}\text{S}_2$ without NH_4^+ intercalation, the bond lengths of Sn-S and W-S are 2.52 Å and 2.43 Å, respectively, and its interlayer distance along the c-axis is ~ 5.94 Å. Interestingly, after NH_4^+ intercalation, the bond length of Sn-S becomes longer (2.55 Å) and that of W-S becomes shorter (2.38 Å). The interlayer distance of $\text{Sn}_{0.5}\text{W}_{0.5}\text{S}_2$ with intercalated NH_4^+ ions also becomes larger.



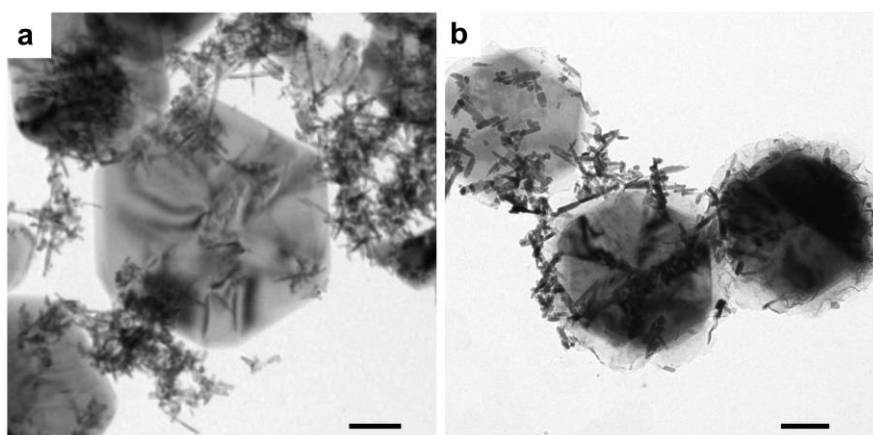
Supplementary Figure 11. Raman spectrum of as-prepared $\text{Sn}_{0.5}\text{W}_{0.5}\text{S}_2/\text{SnS}_2$ heterostructures.



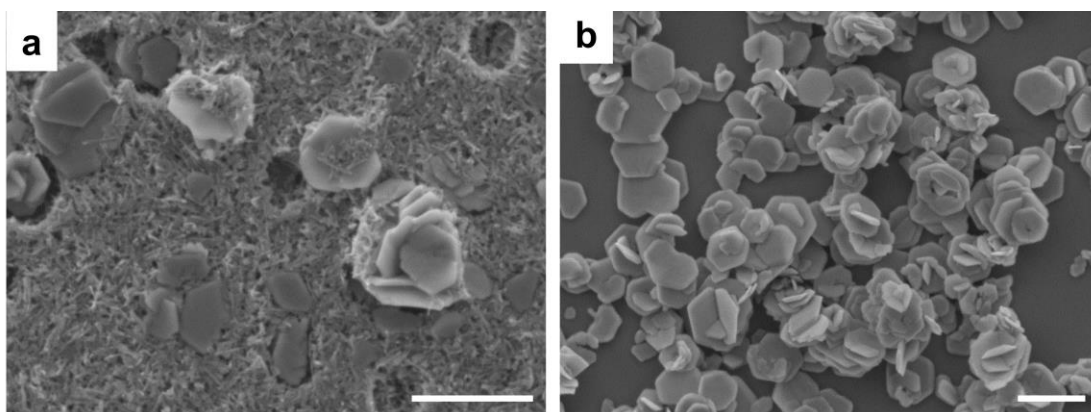
Supplementary Figure 12. (a) TEM image (scale bar, 500 nm), (b) EDX analysis and (c) XRD pattern of $\text{Sn}(\text{HWO}_4)_2 \cdot n\text{H}_2\text{O}$ nanoparticles formed during pre-treatment of precursors in an 80 °C water bath before hydrothermal reaction. The XRD pattern in (c) shows no obvious peaks, suggesting that the $\text{Sn}(\text{HWO}_4)_2 \cdot n\text{H}_2\text{O}$ nanoparticles were amorphous.



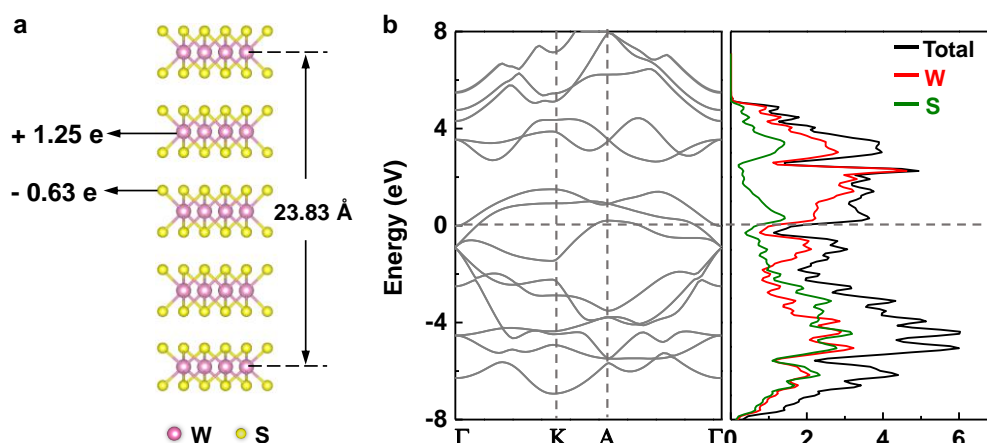
Supplementary Figure 13. (a) STEM image and EDS mapping of intermediate nanorods, confirming the presence of Sn and W elements (scale bar, 100 nm). (b) EDX analysis of the nanorods, where the position of the analyzed area is highlighted in the white rectangle in (a). The Sn:W ratio is about 0.1:0.6, suggesting that $\text{Sn}_{0.17}\text{WO}_3$ was obtained. (c) HRTEM image of the $\text{Sn}_{0.17}\text{WO}_3$ nanorods (scale bar, 5 nm). The measured lattice spacing of 3.7 Å can be assigned to the (110) planes of $\text{Sn}_{0.17}\text{WO}_3$ which show the same structure with previously reported $\text{Sn}_{0.23}\text{WO}_3$ (ICSD NO. 38043).



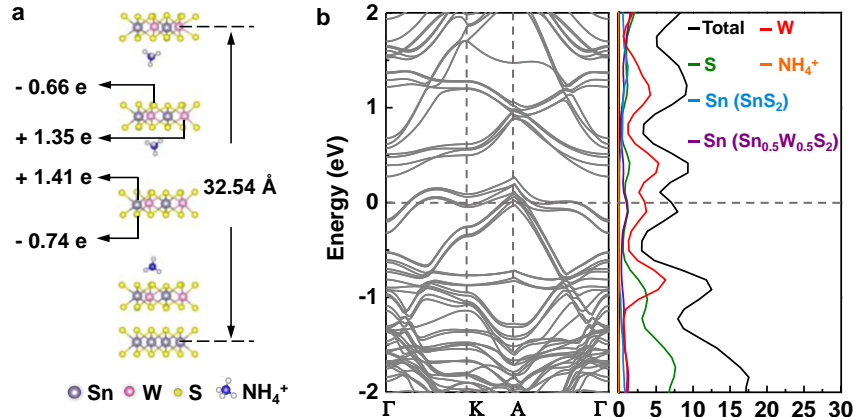
Supplementary Figure 14. TEM images of intermediate products obtained at reaction intervals of (a) 12 h and (b) 48 h, respectively. The scale bars, 200 nm.



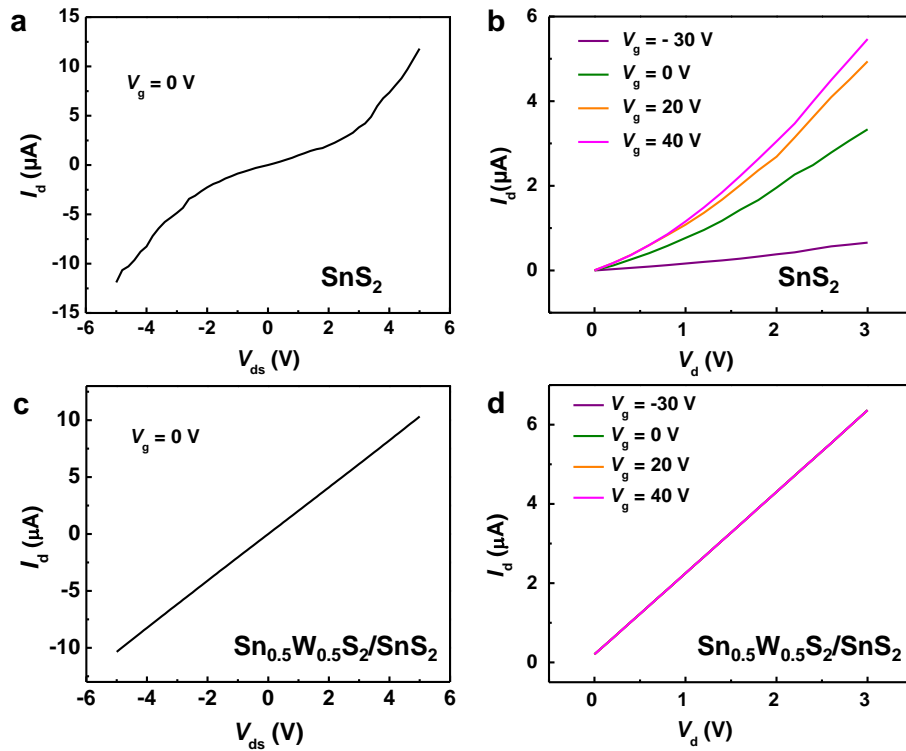
Supplementary Figure 15. SEM images of products synthesized at (a) 180 °C and (b) 200 °C for 60 h, respectively, without changing precursor concentrations (scale bars, 1 μm). It can be seen that $\text{Sn}_{0.17}\text{WO}_3$ nanorods could be prepared together with SnS_2 nanoplates at 180 °C, but were decomposed at 200 °C. $\text{Sn}_{0.5}\text{W}_{0.5}\text{S}_2$ nanosheets were not synthesized at 180 °C or 200 °C. This indicates that reaction at 220 °C with higher energy is needed for the synthesis of alloyed $\text{Sn}_{0.5}\text{W}_{0.5}\text{S}_2$. In addition, the quality of SnS_2 nanoplates prepared at 180 °C and 200 °C was not as good as those prepared at 220 °C.



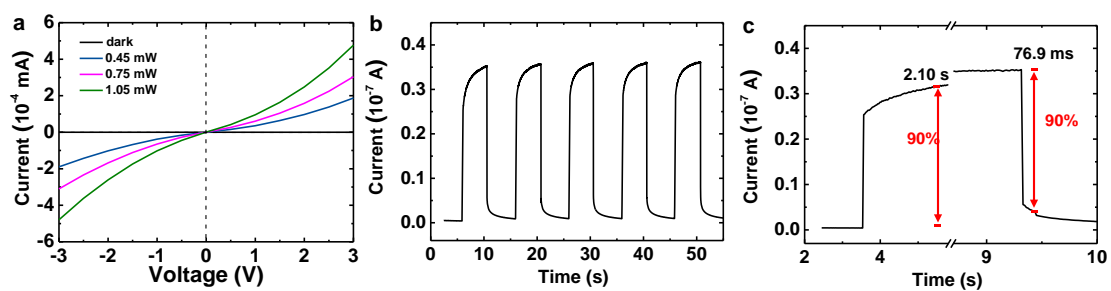
Supplementary Figure 16. (a) Optimized crystal structure with calculated Bader charges, (b) band structure and DOS of a 5-layer 1T- WS_2 , demonstrating an intrinsic metallic behavior. The Fermi level is assigned at 0 eV.



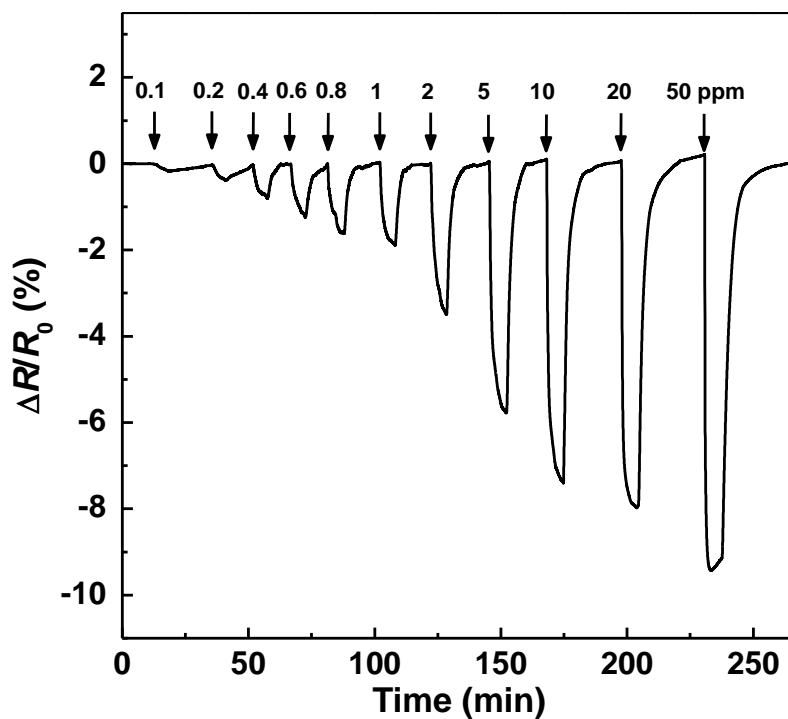
Supplementary Figure 17. (a) Optimized crystal structure with calculated Bader charges, (b) band structure and DOS of a four-layer distorted 1T-Sn_{0.5}W_{0.5}S₂ on a monolayer 1T-SnS₂ with intercalated NH₄⁺ ions, showing an intrinsic metallic characteristic. The Fermi level is assigned at 0 eV.



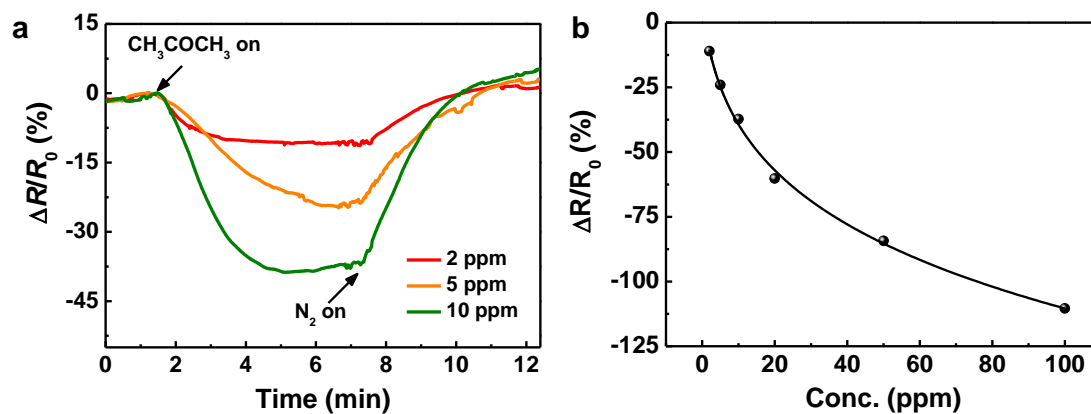
Supplementary Figure 18. Drain current (I_d) characteristics of back-gated TFTs based on (a) SnS₂ nanoplates and (c) Sn_{0.5}W_{0.5}S₂/SnS₂ heterostructures for drain-source voltages (V_{ds}) varied from -5 to 5 V at 0 V gate voltage (V_g). The I_d - V_{ds} curves of (b) SnS₂ nanoplates and (d) Sn_{0.5}W_{0.5}S₂/SnS₂ heterostructures at varied V_g from -30 to 40 V, measured in vacuum (5×10^{-5} Torr) at 77 K.



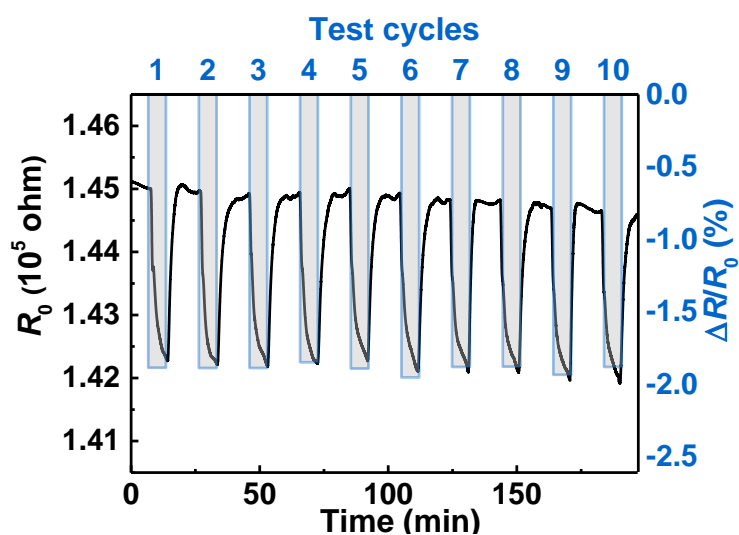
Supplementary Figure 19. (a) I - V curves at different light intensity, (b) temporal photocurrent response and (c) zoom-in view of the temporal photocurrent response of a thin film photodetector based on SnS_2 nanoplates.



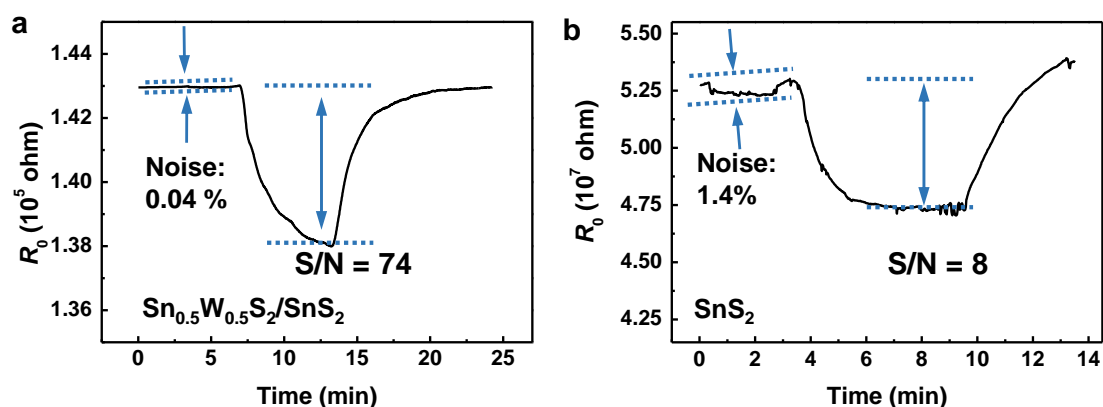
Supplementary Figure 20. Response-recover curve of a typical $\text{Sn}_{0.5}\text{W}_{0.5}\text{S}_2/\text{SnS}_2$ -based sensor in response to acetone with different concentrations from 0.1 to 50 ppm.



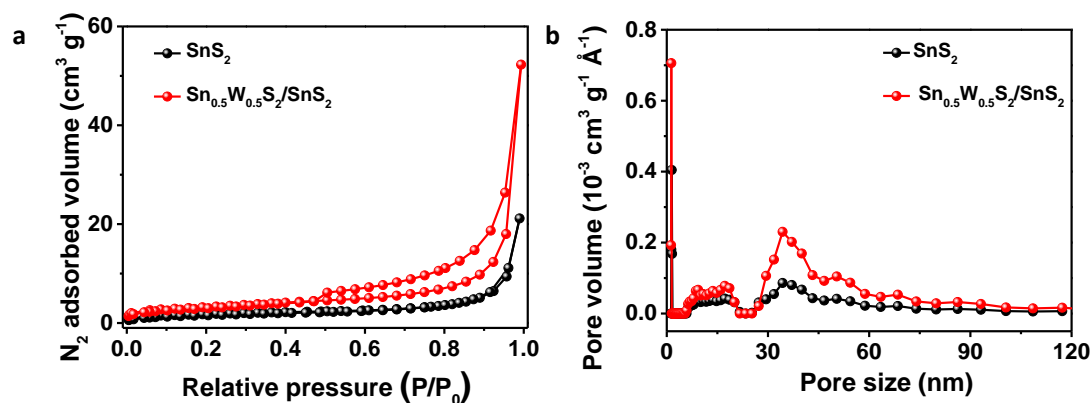
Supplementary Figure 21. (a) Response-recover curves of a typical SnS₂-based sensor in response to acetone with different concentrations from 2 to 10 ppm. (b) Normalized change of resistance of SnS₂ sensor at various acetone concentrations.



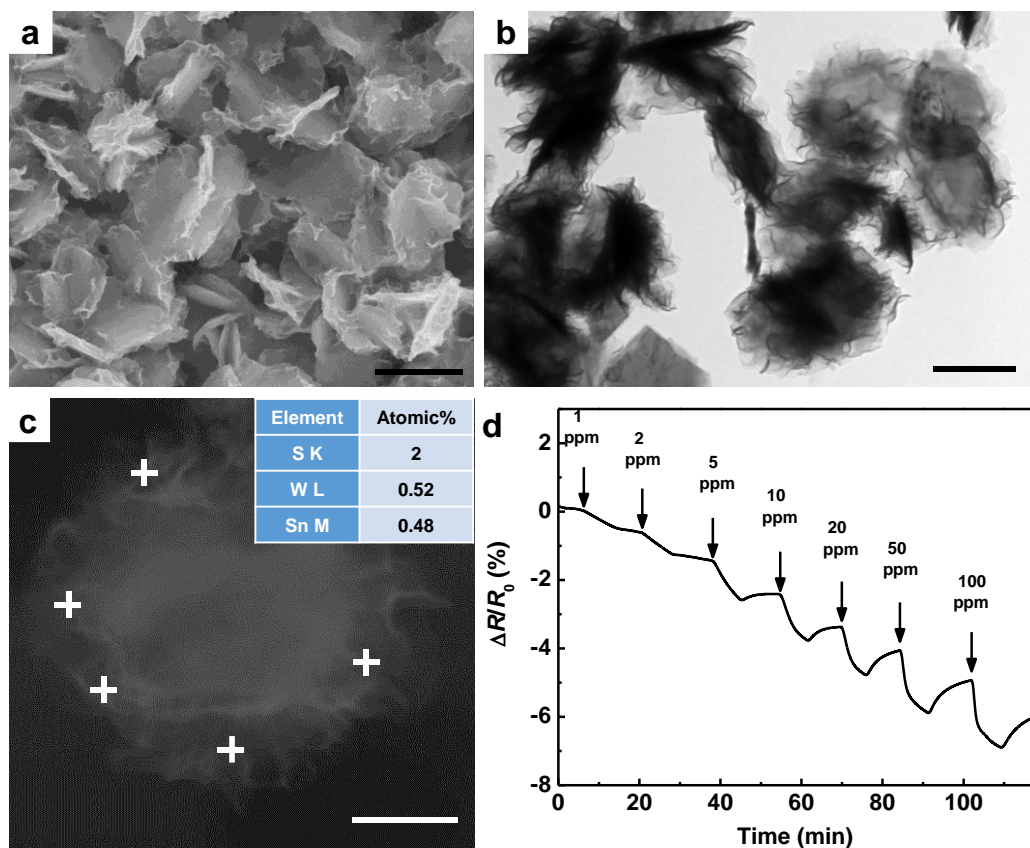
Supplementary Figure 22. Response-recover curve of Sn_{0.5}W_{0.5}S₂/SnS₂ heterostructure based sensor upon cyclic exposure to 1 ppm acetone. Overlaid bar chart: the corresponding responses for the tested 10 cycles.



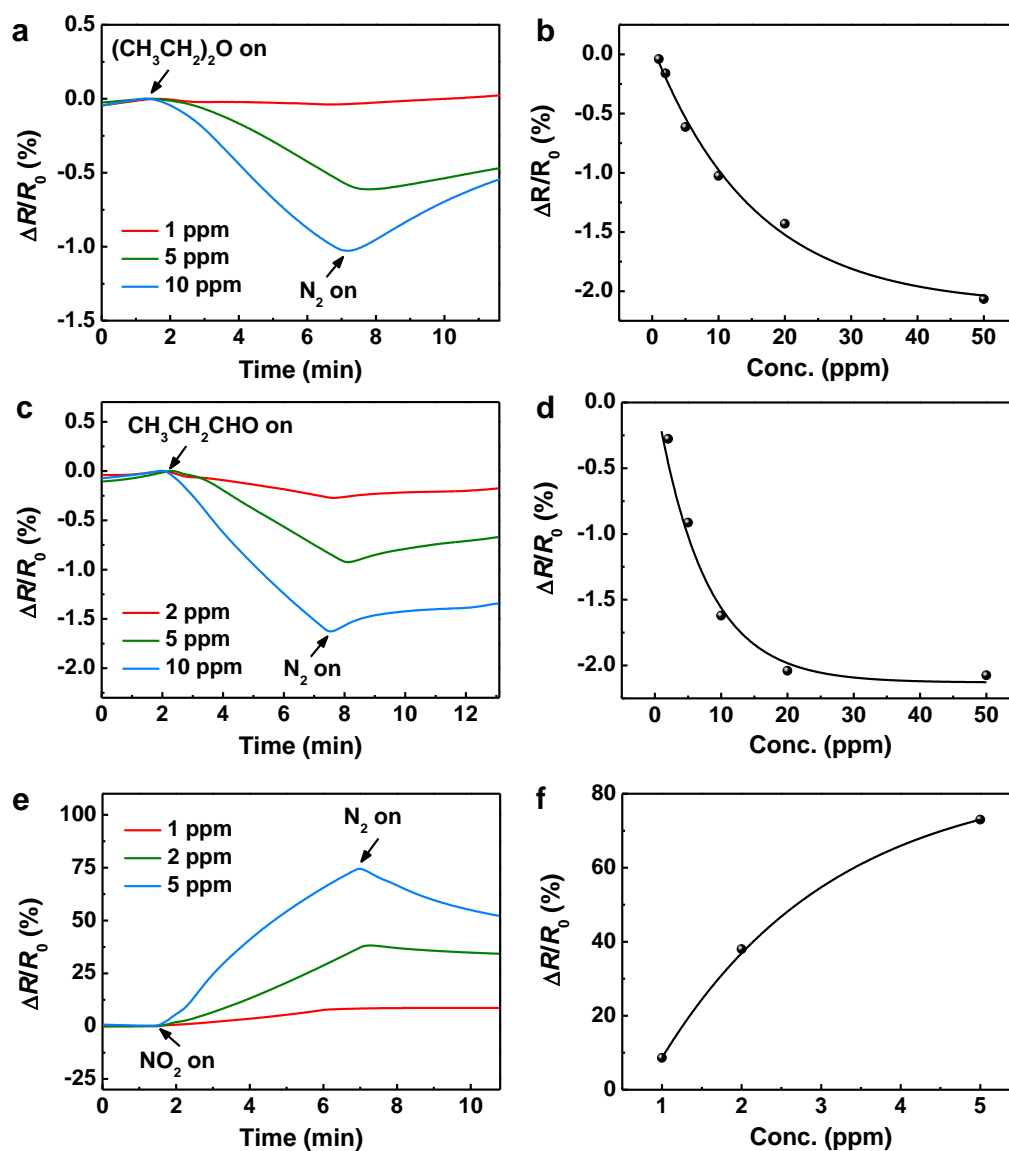
Supplementary Figure 23. The signal to noise ratios (S/N) of sensors based on (a) $\text{Sn}_{0.5}\text{W}_{0.5}\text{S}_2/\text{SnS}_2$ and (b) SnS_2 when responding to 2 ppm acetone.



Supplementary Figure 24. (a) N_2 adsorption-desorption isotherms, and (b) DFT pore size distribution plots for SnS_2 nanoplates and $\text{Sn}_{0.5}\text{W}_{0.5}\text{S}_2/\text{SnS}_2$ heterostructures.



Supplementary Figure 25. (a) SEM image, (b) TEM image and (c) EDX spot analysis of $\text{Sn}_{0.5}\text{W}_{0.5}\text{S}_2/\text{SnS}_2$ heterostructures synthesized with precursors mixed at a Sn:W:S atomic ratio of 1:6:15. Increased amount of wrinkled $\text{Sn}_{0.5}\text{W}_{0.5}\text{S}_2$ nanosheets were found to encapsulate SnS_2 nanoplates. The scale bars in (a), (b) and (c) are 1 μm , 500 nm and 200 nm, respectively. (d) The response-recovery curve of the corresponding $\text{Sn}_{0.5}\text{W}_{0.5}\text{S}_2/\text{SnS}_2$ sensor upon exposure to acetone gas with increasing concentrations from 1 to 100 ppm.



Supplementary Figure 26. Response-recover curves and normalized change of resistance of $\text{Sn}_{0.5}\text{W}_{0.5}\text{S}_2/\text{SnS}_2$ towards different gases including (a,b) diethyl ether, (c,d) propanal and (e,f) NO_2 at different concentrations.

Supplementary Tables

Supplementary Table 1. Optimized lattice parameters, bond lengths and work functions (Φ) of 1T-SnS₂, 1T-WS₂ and a four-layer Sn_{0.5}W_{0.5}S₂ on a monolayer 1T-SnS₂ without and with intercalated NH₄⁺ ions.

System	<i>a</i> (Å)	<i>b</i> (Å)	<i>c</i> (Å)	α (°)	β (°)	γ (°)	Sn-S bond length (Å)	W-S bond length (Å)	Φ (eV)
SnS ₂	3.65	3.65	23.60	90	90	120	2.58	-	5.27
WS ₂	3.15	3.15	23.83	90	90	120	-	2.42	6.62
Sn _{0.5} W _{0.5} S ₂	3.46*	3.46*	23.34	90	90	120	2.52	2.43	5.62
NH ₄ ⁺ -intercalated Sn _{0.5} W _{0.5} S ₂	3.46*	3.46*	32.54	90	90	120	2.55	2.38	2.81

* The experimental lattice constant (3.46 Å) was used in our calculations for the in-plane periodicity of the four-layer Sn_{0.5}W_{0.5}S₂ on a monolayer 1T-SnS₂ without and with NH₄⁺-intercalated systems.

Supplementary Table 2. Concentrations of Sn and W ions measured by ICP-MS for solutions obtained at different reaction intervals.

Ions	5 h	12 h	24 h	48 h	60 h
Sn (μmol/L)	47.2	26.1	31.2	37.1	18.5
W (μmol/L)	566.2	877.9	1482.3	1283.2	1013.9

Supplementary Table 3. Comparison between our Sn_{0.5}W_{0.5}S₂/SnS₂-based sensor and other reported chemiresistive acetone gas sensors operating at room temperature.

Materials	Temperature (°C)	Sensor type	Minimum detectable concentration (ppm)	Response at 0.4 ppm (%)	Response at 0.2 ppm (%)	Ref.
Sn _{0.5} W _{0.5} S ₂ /SnS ₂	25	Chemiresistor	0.1	0.60	0.37	This work
SnS ₂	25	Chemiresistor	2.0	n.d.	n.d.	This work
MoS ₂	25	Chemiresistor	1.0	n.d.	n.d.	4
SnS	25	Chemiresistor	10	n.d.	n.d.	5
Co ₃ O ₄ -ZnS	25	Chemiresistor	10	n.d.	n.d.	6
Ti ₃ C ₂ T _x	25	Chemiresistor	0.05	0.25*	0.18*	7
V ₂ O ₅	25	Chemiresistor	0.9	n.d.	n.d.	8
WO ₃ -polyaniline	25	Chemiresistor	10	n.d.	n.d.	9
TiO ₂	27	Chemiresistor	10	n.d.	n.d.	10
Pt-SnO ₂	25	Chemiresistor	10	n.d.	n.d.	11
SnO ₂ -RGO	25	Chemiresistor	10	n.d.	n.d.	12
ZnO	25	Chemiresistor	2.0	n.d.	n.d.	13
C-ZrO ₂	25	Chemiresistor	10	n.d.	n.d.	14
Ce-ZnO	24	Chemiresistor	1.0	n.d.	n.d.	15
InGa-ZnO	25	Chemiresistor	50	n.d.	n.d.	16
La _{1-x} Sr _x CoO ₃	25	Chemiresistor	10	n.d.	n.d.	17
VO ₂	25	Chemiresistor	5.0	n.d.	n.d.	18
ZnWO ₄	23	Chemiresistor	100	n.d.	n.d.	19
TsCuPc/ZnO	35	Chemiresistor	50	n.d.	n.d.	20
Carbon onions	25	Chemiresistor	37	n.d.	n.d.	21

n.d. means non-detectable.

* denotes estimated value from the reported normalized response curve.

Supplementary References

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